

10/560525

IAP6 Rec'd PCT/PTO 13 DEC 2005

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re the application of:

**Jurgen SCHULZ-HARDER; Kurt MITTEREGGER;  
Karl EXEL and Jurgen WIESSER**

Group Art Unit:

Serial No:

Examiner:

Filed :

For : **METHOD FOR MANUFACTURING  
A CERAMIC-METAL SUBSTRATE**

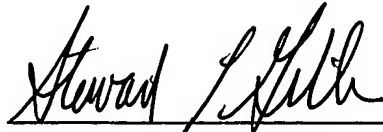
**INFORMATION DISCLOSURE STATEMENT**

Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

In accordance with applicant's duty of disclosure, applicant submits PTO Form 1449 which includes patents the Examiner may find relevant to the examination of the application. The patents were listed in the International Search Report.

Respectfully submitted,



Stewart L. Gitler  
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December 12, 2005

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Attorney's Docket: A-9806.IDS/cat

# INFORMATION DISCLOSURE CITATION

(Use several sheets if necessary)

Docket Number (Optional)

A-9806

Application Number

10/560525

Applicant(s)

Jurgen Schulz-Harder et al

Filing Date

Group Art Unit

## U.S. PATENT DOCUMENTS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE
	A	3,556,366	01/19/1971	Kim			
	B	5,626,777	05/06/1997	Leneis et al			
	C	6,207,221	03/27/2001	Schulz-Harder			
	D	6,420,678	07/16/2002	Hoekstra			
	E	6,444,499	09/03/2002	Glenn et al			

## U.S. PATENT APPLICATION PUBLICATIONS

*EXAMINER INITIAL	REF	DOCUMENT NUMBER	DATE	NAME	CLASS	SUBCLASS	FILING DATE IF APPROPRIATE

## FOREIGN PATENT DOCUMENTS

	REF	DOCUMENT NUMBER	DATE	COUNTRY	CLASS	SUBCLASS	Translation	
							YES	NO

## OTHER DOCUMENTS

(Including Author, Title, Date, Pertinent Pages, Etc.)


EXAMINER

DATE CONSIDERED

EXAMINER: Initial if citation considered, whether or not citation is in conformance with MPEP Section 609; Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.